

KRYJĄCY PODKŁAD DO TWARZY
EVEN & PERFECT SKIN

FULL COVERAGE FOUNDATION
EVEN & PERFECT SKIN

Aqua, Cyclopentasiloxane, CI 77891, Isododecane, Talc, Hydrogenated Polydecene, Propanediol, Propylene Glycol, Lactobacillus/Arundinaria Gigantea Ferment Filtrate, Boron Nitride, Synthetic Fluorophlogopite, Polyglyceryl-4 Isostearate, Cetyl PEG/PPG-10/1 Dimethicone, Hexyl Laurate, Disteardimonium Hectorite, Phenoxyethanol, Magnesium Sulfate, Dimethicone Crosspolymer, Lauryl PEG/PPG-18/18 Methicone, Propylene Carbonate, Acrylates Copolymer, Parfum, Alumina, Triethoxycaprylylsilane, Ethylhexylglycerin, Leuconostoc/Radish Root Ferment Filtrate, Isostearyl Alcohol, Dimethicone/Vinyl Dimethicone Crosspolymer, Alcohol, Dimethiconol, PPG-2-Deceth-30, Sodium Laureth Sulfate, Sodium Dehydroacetate, [+/-]: CI 77492, CI 77491, CI 77499